



Name of article	<b>Struttura</b>	Secondary backing ISO 2424	Action back
Method of production ISO 2424	Tufted	Electrostatic loading ISO 6356	< 2 KV
Width ISO 3018	ca. 400	Surface resistivity ISO 10965 ROT	10 <sup>9</sup> Ω
Surface structure ISO 2424	Loop	Transparency to heat ISO 8302	0,09 K*m <sup>2</sup> /W
Colourways	Style	Light fastness ISO 105-B02	≥ 6
Pile material ISO 2424	100% Econyl by Aquafil	Water fastness EN ISO 105 E01	≥ 5
Primary backing ISO 2424	PES	Friction fastness EN ISO 105-X12	≥ 5
Overall weight ISO 8543	ca. 2000 g/m <sup>2</sup>	Stitch rate ISO 1763	ca. 250.000/m <sup>2</sup>
Overall thickness ISO 1765	ca. 7,0 - 8,0 mm		
Pile service weight	ca. 800 g/m <sup>2</sup>		



EN 14041 | DOP: 1060 OC 3379 | NB: 1658

### Health-promoting properties AIR



- Free from PVC and bitumen.
- Free from formaldehyde.
- Reduction of fine dust in the breathing air.
- Free from harmful emissions and odors.
- TVOC limits are immediately met.
- Suitable for allergy sufferers

HEALTH



### Health-promoting ACOUSTIC properties



- Improved impact sound insulation +25dB
- Enhanced room acoustics +0.25α<sub>w</sub>

Hz	125	250	500	1000	2000	4000
α <sub>s</sub>	0,02	0,06	0,28	0,32	0,40	0,45

- Increased employee concentration and motivation through enhanced well-being
- Acoustically effective

### Environmental properties

C9857DCD  
PRODISE-ID | product pass

- 100% recycled yarn
- Recycled primary backing
- Easy cleaning with water only



### Product Information

The smallest twisted yarn loops create a structured yet homogeneous texture. The delayed regeneration behavior of the tufting is typical of the fabric. Indentations in the fibers recover after a short period of frequent use.

### Installation Instructions

The seam is cut professionally from above within the nap alley using a seam cutter (e.g. from Mittag). During this work process, it must be ensured that the nap alley is not left during cutting.



Made in Europe (production according to EU standard)

Data status 23.07.2024. Subject to changes due to technical advancements.